
4AM11

Silicon N-Channel/P-Channel Power MOS FET Array

HITACHI

Application

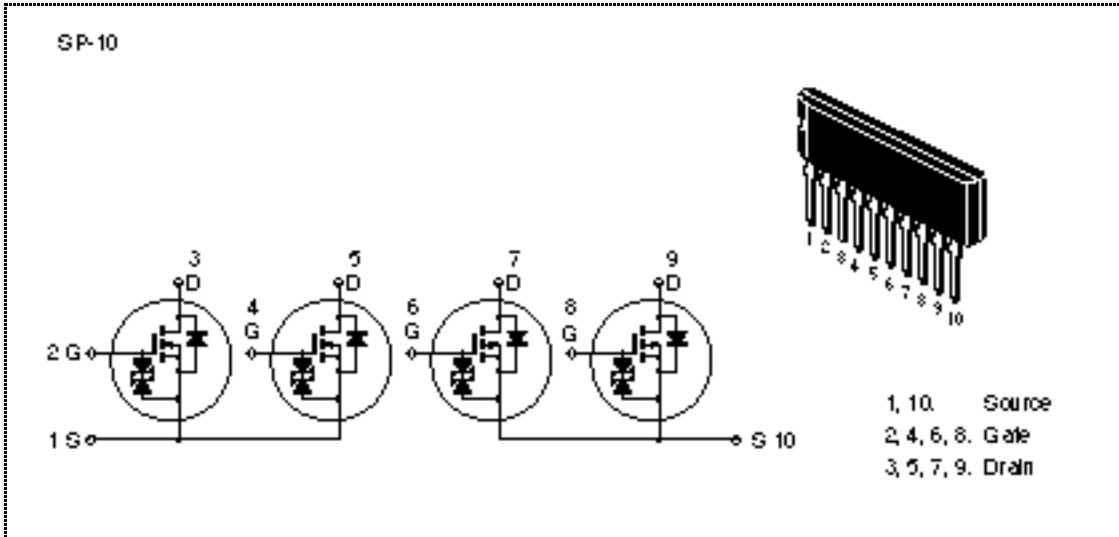
High speed power switching

Features

- Low on-resistance
N-channel: $R_{DS(on)} = 0.17 \Omega$, $V_{GS} = 10 \text{ V}$, $I_D = 2.5 \text{ A}$
P-channel: $R_{DS(on)} = 0.2 \Omega$, $V_{GS} = -10 \text{ V}$, $I_D = -2.5 \text{ A}$
- Capable of 4 V gate drive
- Low drive current
- High speed switching
- High density mounting
- Suitable for H-bridged motor driver

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Outline



Absolute Maximum Ratings (Ta = 25°C) (1 Unit)

| Item | Symbol | Rating | | |
|---|----------------------------------|-------------|-----|------|
| | | Nch | Pch | Unit |
| Drain to source voltage | V_{DSS} | 60 | -60 | V |
| Gate to source voltage | V_{GSS} | ±20 | ±20 | V |
| Drain current | I_D | 5 | -5 | A |
| Drain peak current | $I_{D(pulse)}^{*1}$ | 20 | -20 | A |
| Body to drain diode reverse drain current | I_{DR} | 5 | -5 | A |
| Channel dissipation | $P_{ch} (T_c = 25^\circ C)^{*2}$ | 28 | | W |
| Channel dissipation | P_{ch}^{*2} | 4 | | W |
| Channel temperature | T_{ch} | 150 | | °C |
| Storage temperature | T_{stg} | -55 to +150 | | °C |

Notes: 1. PW 10 μs, duty cycle 1%

2. 4 Devices operation

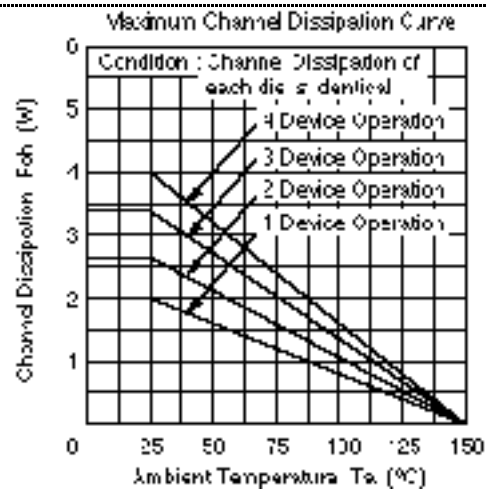
Electrical Characteristics (Ta = 25°C) (1 Unit)

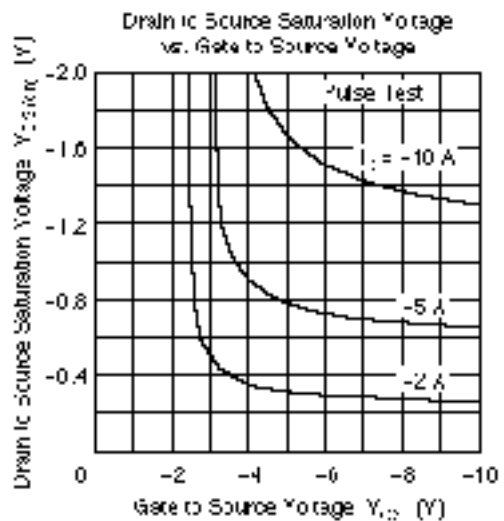
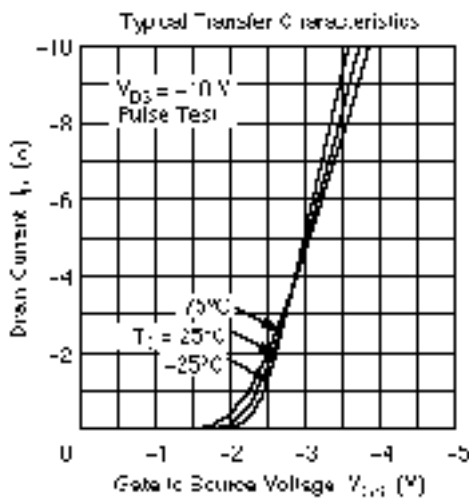
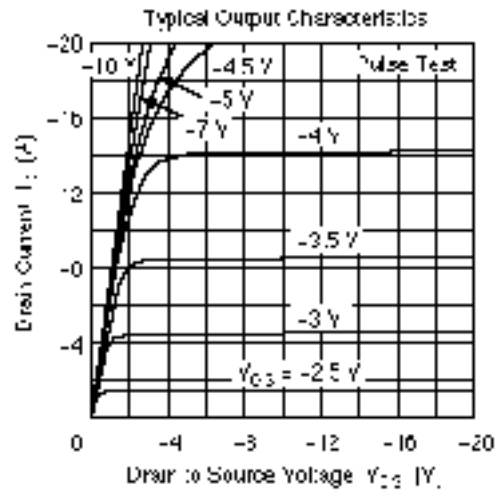
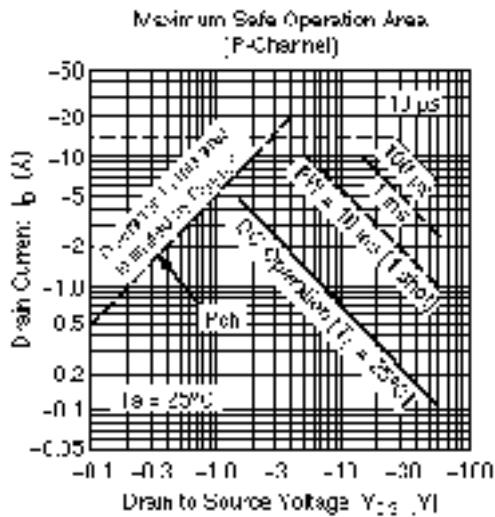
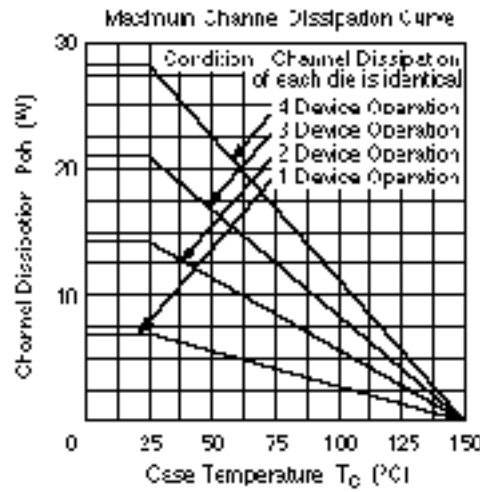
| Item | Symbol | N channel | | | P channel | | | Unit | Test conditions |
|--|---------------|-----------|------|----------|-----------|------|----------|---------------|--|
| | | Min | Typ | Max | Min | Typ | Max | | |
| Drain to source breakdown voltage | $V_{(BR)DS}$ | 60 | — | — | -60 | — | — | V | $I_D = 10 \text{ mA}, V_{GS} = 0$ |
| Gate to source breakdown voltage | $V_{(BR)GS}$ | ± 20 | — | — | ± 20 | — | — | V | $I_G = \pm 100 \text{ } \mu\text{A}, V_{DS} = 0$ |
| Gate to source leak current | I_{GSS} | — | — | ± 10 | — | — | ± 10 | μA | $V_{GS} = \pm 16 \text{ V}, V_{DS} = 0$ |
| Zero gate voltage drain current | I_{DSS} | — | — | 250 | — | — | -250 | μA | $V_{DS} = 50 \text{ V}, V_{GS} = 0$ |
| Gate to source cutoff voltage | $V_{GS(off)}$ | 1.0 | — | 2.0 | -1.0 | — | -2.0 | V | $I_D = 1 \text{ mA}, V_{DS} = 10 \text{ V}$ |
| Static drain to source on state resistance | $R_{DS(on)}$ | — | 0.13 | 0.17 | — | 0.15 | 0.2 | | $I_D = 2.5 \text{ A},$ $V_{GS} = 10 \text{ V}^{*1}$ |
| | | — | 0.18 | 0.24 | — | 0.20 | 0.27 | | $I_D = 2.5 \text{ A}, V_{GS} = 4 \text{ V}^{*1}$ |
| Forward transfer admittance | $ y_{fs} $ | 2.7 | 4.5 | — | 2.7 | 5.0 | — | S | $I_D = 2.5 \text{ A},$ $V_{DS} = 10 \text{ V}^{*1}$ |
| Input capacitance | C_{iss} | — | 400 | — | — | 900 | — | pF | $V_{DS} = 10 \text{ V}, V_{GS} = 0,$ |
| Output capacitance | C_{oss} | — | 220 | — | — | 460 | — | pF | $f = 1 \text{ MHz}$ |
| Reverse transfer capacitance | C_{rss} | — | 60 | — | — | 130 | — | pF | |
| Turn-on delay time | $t_{d(on)}$ | — | 5 | — | — | 8 | — | ns | $I_D = 2.5 \text{ A}, V_{GS} = 10 \text{ V},$ |
| Rise time | t_r | — | 30 | — | — | 35 | — | ns | $R_L = 12$ |
| Turn-off delay time | $t_{d(off)}$ | — | 170 | — | — | 180 | — | ns | |
| Fall time | t_f | — | 75 | — | — | 85 | — | ns | |
| Body to drain diode forward voltage | V_{DF} | — | 1.0 | — | — | -1.0 | — | V | $I_F = 5 \text{ A}, V_{GS} = 0$ |
| Body to drain diode reverse recovery time | t_{rr} | — | 100 | — | — | 170 | — | μs | $I_F = 5 \text{ A}, V_{GS} = 0,$ $dI_F/dt = 50 \text{ A}/\mu\text{s}$ |

Note: 1. Pulse Test

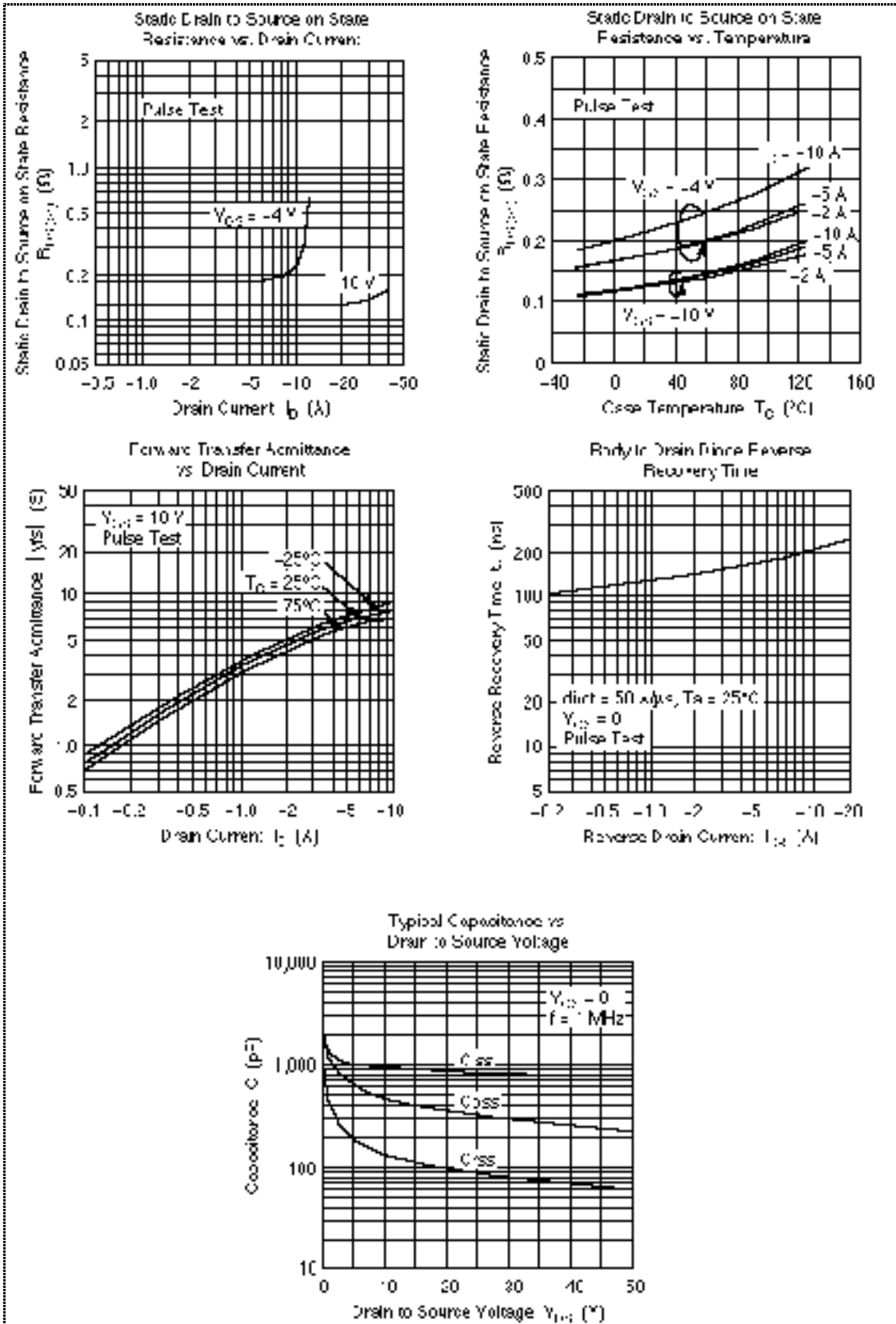
Polarity of test conditions for P channel device is reversed.

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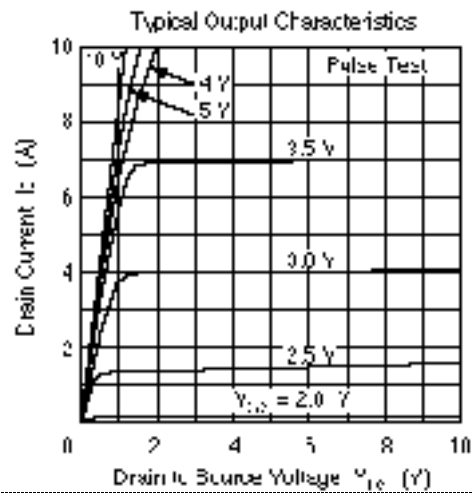
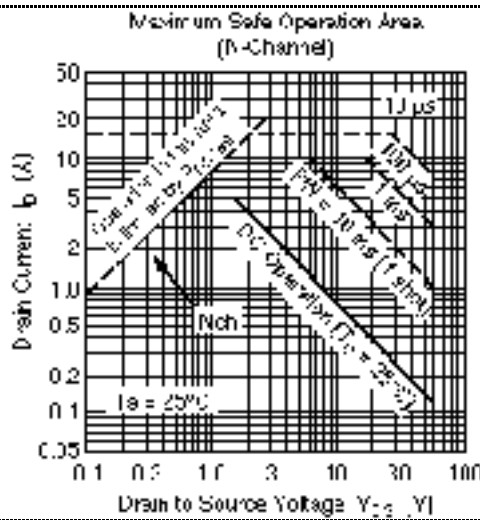
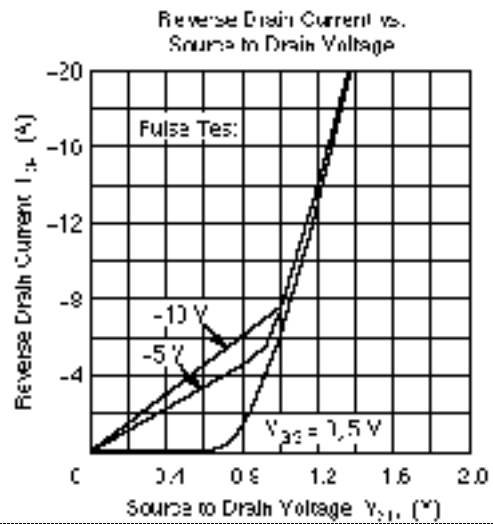
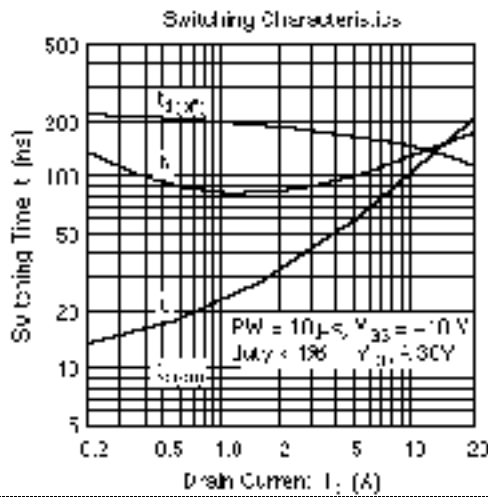
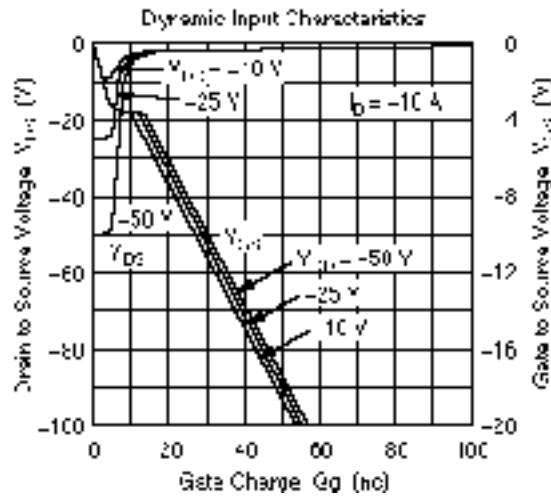




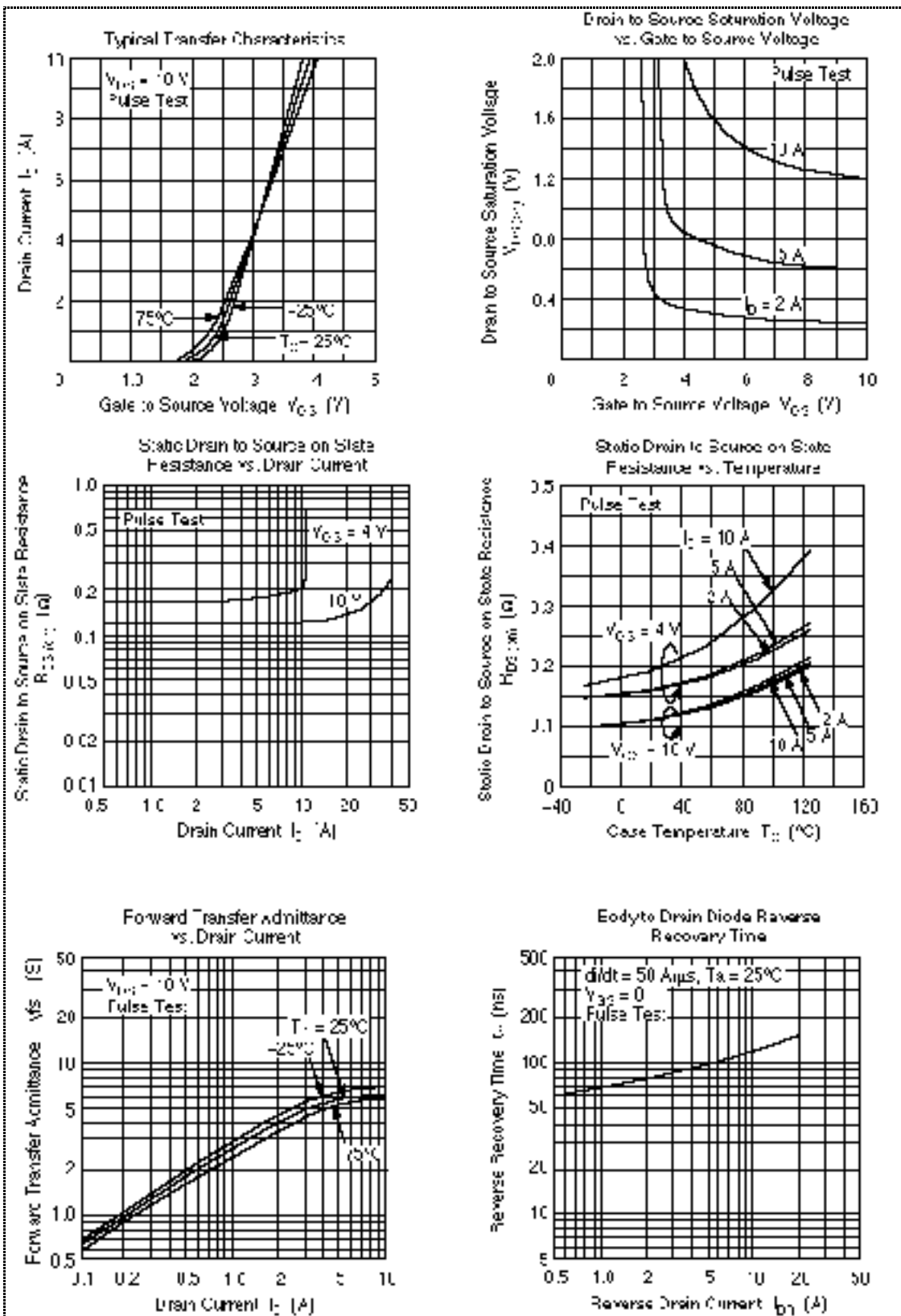
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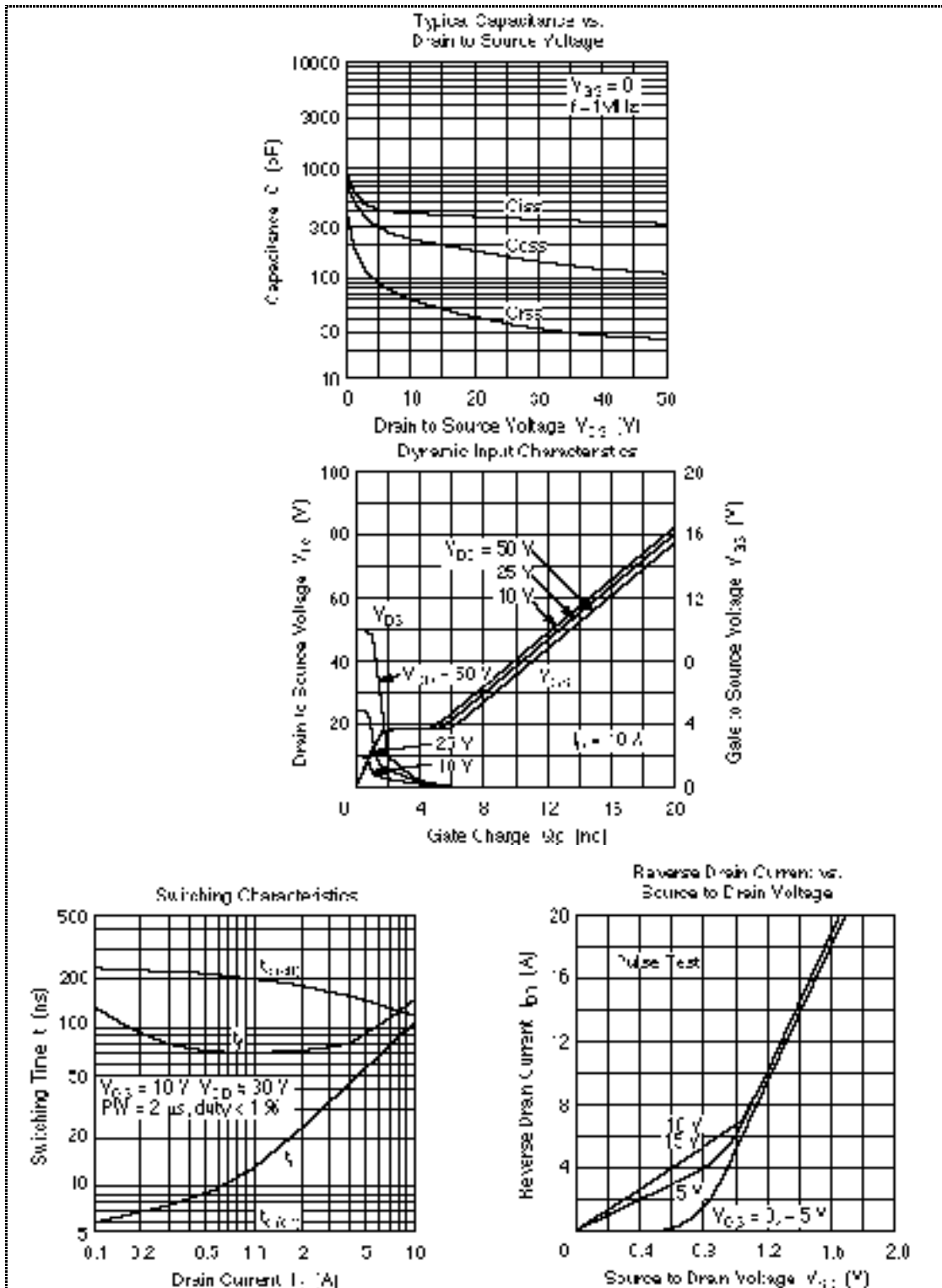
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